

Transaction Information

Tool ID	STP420
Tool Status	Running Wafers
Location	
Wafer Size	300 mm
Fab Section	Lithography
Tool Available Date	2024-04-30

General Product Information

Vendor Supplier	NIKON
Model	NSR-S208D
Vintage	2005
Serial No	
Asset Description	Lithography Step and repeat scanning system
Software Version	1.80 MCSW+OCS
CIM	SECS
Process	Exposure Wafers (248nm) KrF

Hardware Configuration (Fab)

System Type	Description	Quantity	Status
Main System	NA		
Handler System	Wafer Handler System	1	OK
Handler System	Reticle Handler System	1	OK
Options System			
Others	Chiller	1	OK
Others	Chamber_Filter_Cabinett LFU	1	OK
Others	A/C Bower Box	1	OK

Hardware Configuration (Subfab / Auxilliary Units)

Description	Quantity	Status
left site operation unit	1	OK

Missing/Faulty Parts / Accesories List

Description	Quantity
NONE	